# Chapter 21 Sustainable Energy Harvesting Using Efficient  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> Photoanode Through Photocatalytic Water Splitting Using Facile Chemical Route

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Abstract Here, a simple, controlled and cost effective electrodeposition technique was used to synthesize  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> hematite photo-electrode for solar water splitting. We have synthesized thin films of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> by varying electrodeposition potential from −0.2 to 0 V at optimum conditions of cycles by using potentiostat. The obtained ferrihydrite thin films were transformed into  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films by annealing them at  $600 \degree C$  for 1 h. Films were investigated by XRD, SEM, UV-Visible and Raman spectroscopy for their structural, optical and morphological properties. Further suitability of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films as a photo-electrode has been evaluated by photoelectrochemical (PEC) measurements which exhibited photocurrent density of 65  $\mu$ A/cm<sup>2</sup> at 0.5 V versus SCE under AM 1.5 100 mW/cm<sup>2</sup> illumination. The effective enhancement in photocurrent conversion efficiency with optimum film thickness has been observed upon light irradiation. The absorption spectrum of the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> shows significant absorption in the visible region. However, photo-conversion efficiency is quite low. The obtained results suggest that the well controlled thick  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> material can be utilized as a shell layer with wide band gap nano-structured semiconductor like  $ZnO$ ,  $TiO<sub>2</sub>$  to form hetero-structure for solar water splitting application.

Keywords  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> · Photoelectrochemical · XRD · SEM · UV-Visible spectroscopy · Raman spectroscopy

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# 21.1 Introduction

Semiconductor photocatalyst is one of the most promising technologies for conversion of solar energy into hydrogen via water-splitting process for the future fuel is a viable alternative to fossil fuels because large quantity of hydrogen can potentially be generated in a clean and sustainable manner [\[1](#page-6-0)]. Fujishima and Honda in 1972 demonstrated the phenomenon of photocatalysis using single crystal TiO<sub>2</sub> as a working electrode [\[2](#page-6-0)]. Iron oxide ( $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>) is an important semiconductor which has recently attracted the attention for production of hydrogen via water splitting. It has the ability to absorb a large part of solar spectrum due to its favorable band gap  $(2.0-2.2 \text{ eV})$   $[3, 4]$  $[3, 4]$  $[3, 4]$ . It is also inexpensive, plentiful, readily available, non toxic, chemically stable in aqueous environment and has good environmental acceptability [[5,](#page-6-0) [6\]](#page-6-0) which favors the fundamental and practical research for its applications in many fields such as Li-ion batteries [\[7](#page-7-0), [8](#page-7-0)], supercapacitors [\[9](#page-7-0)], peroxide sensor [\[10](#page-7-0)], solar energy conversion via water splitting [\[11](#page-7-0)], dye degradation [[12\]](#page-7-0), water purification and treatment [\[13](#page-7-0), [14](#page-7-0)]. Thus, study of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films for photocatalytic water splitting is a important topic of research in production of hydrogen fuel. The maximum theoretical solar-to-hydrogen (STH) conversion efficiency at standard solar illumination conditions for  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> was found  $\sim 15\%$  [[15,](#page-7-0) [16\]](#page-7-0).

The  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films can be prepared by various methods such as chemical vapor deposition [\[17](#page-7-0)], sol-gel process [\[18\]](#page-7-0), pulsed laser evaporation [[19](#page-7-0)], reactive sputtering  $[20]$  $[20]$ , hydrothermal technique  $[15, 21]$  $[15, 21]$  $[15, 21]$  $[15, 21]$ , spray pyrolysis  $[22, 23]$  $[22, 23]$  $[22, 23]$  $[22, 23]$  $[22, 23]$  etc. However, for preparation of hematite  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films there are certain challenges which need to be overcome such as non-optimal conduction band edge alignment for hydrogen evolution potential and indirect band gap causing low absorption of light. Also it possesses short carrier diffusion length in the range of 2–4 nm [[24\]](#page-7-0), 20 nm [\[25](#page-7-0)] giving low transport and low conductivity of photo generated carriers [\[11](#page-7-0), [26](#page-8-0)]. The short diffusion length of holes can be overcome by synthesis of extremely thin films of hematite  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> material by controlled deposition technique. With this motivation an attempt has been made to prepare  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films of well-defined thickness by simple electrochemical deposition technique. This technique consists of three electrode system with FTO coated glass working substrate, platinum counter electrode and SCE as the reference electrode. In this study we have tried to use thin films of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> as working electrode by controlling thickness of deposition layers using cyclic voltammetry.

### 21.2 Experimental

The potentiostatic electrochemical deposition were performed by an Metrohm Autolab potentiostat PGSTAT302 N model in three-electrode cell configuration system controlled by a personal computer (PC), working electrode (FTO glass substrate), reference electrode (SCE) and counter electrode (Pt). The FTO coated glass substrate were ultrasonically cleaned before starting the deposition using acetone, ethanol and distilled water for 5 min each. The chemical solution were prepared using aqueous electrolyte of 0.05 M Ferric Chloride (FeCl<sub>3</sub>), 0.05 M Potassium Fluoride (KF), 0.1 M Potassium Chloride (KCl) and 1 M Hydrogen Peroxide (H<sub>2</sub>O<sub>2</sub>). The films of Fe<sub>2</sub>O<sub>3</sub> are electrochemically synthesized by 30 deposition cycles from −0.2 to 0 V (scan rate 20 mV/S) at room temperature. The obtained ferrihydrite thin films were transformed into  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films by annealing at 600  $^{\circ}$ C in ambient atmosphere for 1 h. The surface morphology of the films was analysed using a JEOL JSM-6360A scanning electron microscope (SEM) with operating voltage 20 kV. The optical band gap of the films was calculated from absorption spectra and was measured in the range of 200–800 nm using a JASCO, V-670 UV-Visible spectrophotometer. Rein-shaw Raman spectrometer was used to record raman spectra in the range of 100–800 cm<sup>-1</sup>. Raman spectrum was detected using the spectrometer having backscattering geometry with the resolution of 1 cm−<sup>1</sup> . The He–Ne laser of 632.8 nm line was used as the excitation source at room temperature. To avoid laser induced crystallization the power of the Raman laser was kept less than 5 mW. X-ray diffractometer (Bruker D8 Advance, Germany) using CuK $\alpha$  line ( $\lambda = 1.54$  Å) was used to obtain the x-ray diffraction patterns. The photoelectrochemical measurements with a potentiostat (AUTOLAB N302) were carried out in a three electrode configuration by employing a platinum foil as the counter, SCE as the reference and  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> as working electrode. The 1 M NaOH was used as an aqueous electrolyte. The Electrochemical Impedance Spectra (EIS) measurement was recorded under illumination and darkness.

#### 21.3 Results and Discussion

# 21.3.1 Structural and Phase Analysis

The structure and phase of the films was analyzed using x-ray diffraction (XRD) and Raman spectroscopy. Figure [21.1a](#page-3-0) shows the XRD pattern of the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film. The presence of multiple numbers of peaks in XRD pattern suggests the polycrystalline nature of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> film. As seen from the figure main diffraction peaks were observed at  $2\theta \sim 24.2^{\circ}, 33.2^{\circ}, 35.5^{\circ}, 54.5^{\circ}, 61.5^{\circ}$  and 64.1<sup>o</sup> corresponding to  $(012)$ ,  $(104)$ ,  $(110)$ ,  $(116)$ ,  $(213)$  and  $(300)$  crystal orientations respectively [\[27](#page-8-0), [28](#page-8-0)]. These peaks are in agreement with JCPDS data file # 33-0664 of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> with hexagonal crystal structure. The \* indicates the diffraction peaks obtained from FTO glass substrate. The lattice parameters are calculated from peaks  $a = 5.03$  Å and  $c = 13.7$  Å, which are in agreement with standard reported values

<span id="page-3-0"></span>

Fig. 21.1 a XRD pattern and b Raman spectra of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films electrodeposited on FTO substrate



Fig. 21.2 UV-Visible absorbance spectra of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film. Inset shows Tauc's plot of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film used for estimation of band gap of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film

for  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> crystal structure. The crystallite domain size calculation was performed for the major diffraction peak (200) using the Scherrer's formula,

$$
d_{x-ray} = \frac{0.9 \lambda}{\beta \cos \theta_{\beta}}
$$
 (21.1)

where  $\lambda$  is the wavelength of the x-ray used,  $\beta$  is full-width at half-maximum (FWHM) and  $\theta_B$  is the Bragg diffraction angle. The estimated average grain size using Scherrer's formula was found to be  $\sim$  29 nm (Fig. 21.1a).

Raman spectroscopy is a powerful characterization tool to investigate molecular, vibration and chemical structure by interacting laser light with the sample. It is a non-destructive technique that offers a fast and simple way to determine the phase of the film. Figure 21.1b shows the Raman spectra of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film in the range 100–800 cm−<sup>1</sup> deposited for 30 electrochemical cycles. As shown in figure major



Fig. 21.3 Scanning electron microscopy images of electrodeposited  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> on FTO substrate at two different magnifications a At 30,000 and b At 60,000

Raman peaks were observed at  $\sim$  224, 245, 293, 409, 497, 610 and 663 cm<sup>-1</sup>. The Raman peaks located at  $\sim$  224 and  $\sim$  497 cm<sup>-1</sup> corresponds to the A<sub>1g</sub> mode whereas other peaks located at  $\sim$  245,  $\sim$  293,  $\sim$  410,  $\sim$  610 and 663 cm<sup>-1</sup> corresponds to Eg mode of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> [[27,](#page-8-0) [28\]](#page-8-0). No other peaks were observed in the Raman spectra suggesting the formation of pure phase of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>.

# 21.3.2 Optical Analysis

In order to reveal the optical properties of the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films, UV-Visible spectroscopy has been used. Figure [21.2](#page-3-0) shows the UV-Visible absorption spectra of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> synthesized by electrodeposition. As seen the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> exhibits a strong excitonic absorption around  $\sim 620$  nm. Tauc relation was used to calculate the optical band gap ( $E_{\text{opt}}$ ) of the electrodeposited  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> film [[29\]](#page-8-0),

$$
(\alpha E)^{1/2} = B^{1/2} (E - E_{opt})
$$
\n(21.2)

where  $\alpha$  is the absorption coefficient, B is the optical density of state and E is the photon energy. The optical band can be then calculated from a linear fit of the  $(hv)^{1/2}$  versus hv plot (Tauc plot) [\[29\]](#page-8-0). Inset of Fig. [21.2](#page-3-0) shows typical Tauc plot for the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film. The estimated value of optical band gap was found to be  $\sim$  1.9 eV.

# 21.3.3 Surface Morphological Analysis

Scanning electron microscopy (SEM) was used to investigate the surface morphology of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film. Figure 21.3a, b show typical SEM micrographs of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film taken at two different magnifications. The surface of the films

shows granular morphology with uniform and dense growth of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> on the FTO surface without having defects such as cracks, pinholes, and protrusion. The compositional analysis of the  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film was carried out using energy dispersive x-ray analysis (EDAX) technique and found that Fe and O are approximately in the ratio of 2:3.

# 21.3.4 Photoelectrochemical (PEC) Measurements

The grown  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films were used as working electrode (WE) in PEC cell. Electrochemical cell was used to conduct PEC performance, which was fitted with a water jacket around it, to prevent heating. Placed inside the cell were three electrodes;  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin film working electrode (WE), platinum foil counter electrode (CE), and saturated calomel reference electrode (SCE). 1 M NaOH was used as an aqueous electrolyte. Metrohm Autolab Potentiostat (PGSTAT302 N) and 150 W Xenon Lamp (PEC-L01) with 100 mW/cm<sup>2</sup> (AM 1.5) illumination intensity were used to record J-V characteristics, both under darkness and illumination.

To study the PEC performance of the synthesized  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> photoelectrodes we have performed electrochemical impedance spectroscopy (EIS) in a frequency range varying from 0.1 Hz to 100 kHz at a bias of 0 V versus SCE under UV-Visible light irradiation. The Nyquist diagram of EIS data is an effectual way to measure the electron transfer resistance. The arc radius in the Nyquist plot is directly related to electron transfer resistance reflecting energy barrier of the electrode reaction [\[30](#page-8-0)]. Figure 21.4a shows the EIS measurements using the Nyquist plot. The minimum of arc radius ( $\sim$  25  $\Omega$ ) shown in Fig. 21.4a reveals that there is large reduction in interfacial resistance between semiconductor and electrolyte due to the absorption of light and separation of electron-hole pairs away from interface. The photoelectrochemical (PEC) performance shown in Fig. 21.4b also supports this. The incident photon creates electron-hole pair when absorbed within photo electrode due to ejection of an electron from the valence band into the conduction



Fig. 21.4 a EIS Nyquist plot and b Photoelectrochemical (PEC) performance of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films electrodeposited on FTO substrate

<span id="page-6-0"></span>band, leaving behind a hole in the valence band. The electron reduces the absorbed H<sup>+</sup> to produce H<sub>2</sub> and the hole oxidizes the OH<sup>-</sup> ions to form stable OH [\[31](#page-8-0)]. In  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> it is difficult to separate photogenerated carriers due to the recombination loss and low diffusion length of charge carriers. However, in the present study an attempt has been made to obtain high photocurrent density with optimum film thickness. An excellent PEC performance for water splitting with higher photocurrent density  $\sim 65$  µA/cm<sup>2</sup> at 0.5 V versus SCE under 100 mW/cm<sup>2</sup> illumination has been obtained.

# 21.4 Conclusions

In summary, hematite ( $\alpha$ -Fe<sub>2</sub>O<sub>3</sub>) thin films photo-electrode were synthesized using a simple, controlled and cost effective electrodeposition technique for solar water splitting. Films were investigated using XRD, SEM, UV-Visible and Raman spectroscopy for their structural, optical and morphological properties. Further suitability of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> thin films as a photo-electrode has been evaluated by photoelectrochemical (PEC) measurements with photocurrent density of 65  $\mu$ A/cm<sup>2</sup> at  $0.5$  V versus SCE under AM  $1.5$   $100$  mW/cm<sup>2</sup> illumination. The absorption spectrum of  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> shows significant absorption in the visible region. However, photo-conversion efficiency is quite low. The obtained results suggest that a well controlled thick  $\alpha$ -Fe<sub>2</sub>O<sub>3</sub> material can be use as a shell layer with wide band gap nano-structured semiconductor like  $ZnO$ ,  $TiO<sub>2</sub>$  to form hetero-structure for solar water splitting application. The effective enhancement in photocurrent conversion efficiency with optimum film thickness has been observed upon light irradiation.

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